

L Number	Hits	Search Text	DB	Time stamp
-	77203	lithography patterning	USPAT; US-PGPUB	2003/06/10 10:49
-	46889	beam with radiation) (flood with electron with beam	USPAT; US-PGPUB	2003/06/10 10:49
-	5073	(lithography patterning) and (beam with radiation) (flood with electron with beam)	USPAT; US-PGPUB	2003/06/09 14:09
-	2306	((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)	USPAT; US-PGPUB	2003/06/09 14:09
-	80	(((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and etching with polysilicon	USPAT; US-PGPUB	2003/06/10 10:51
-	25	5139904.URPN.	USPAT	2003/06/09 14:58
-	1	6183937.URPN	USPAT	2003/06/09 14:59
-	7	("5139904" "5965461" "6107172" "6121155" "6153477" "6183937" "6232048").PN.	USPAT	2003/06/09 14:59
-	19	(((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and trim with etch\$3	USPAT; US-PGPUB	2003/06/09 15:29
-	14	("5264076" "5773199" "5837428" "5858621" "6080678" "6096659" "6136679" "6156629" "6218292" "6221776" "6297170" "6352922" "6365529" "6410421").PN.	USPAT	2003/06/09 15:50
-	23	5773199.URPN.	USPAT	2003/06/09 15:51
-	12	("Re30505" "3920483" "4253888" "5139904" "5308742" "5326727" "5368989" "5407787" "5656128" "5733714" "5753418" "5773199").PN.	USPAT	2003/06/09 15:52
-	14	("4625120" "4749436" "4868095" "4876177" "5096802" "5300403" "5385804" "5635333" "5641715" "5648198" "5650262" "5652084" "5660957" "5837428").PN.	USPAT	2003/06/09 16:02
-	6	("(6232048") or ("6197687") or ("6110837") or ("5876903") or ("5468595") or ("3997367")).PN.	USPAT; US-PGPUB	2003/06/10 10:48
-	4752	((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)).CCLS.	USPAT; US-PGPUB	2003/06/10 10:49
-	77388	lithography patterning	USPAT; US-PGPUB	2003/06/10 10:49
-	78540	beam with radiation) (flood with electron with beam	USPAT; US-PGPUB	2003/06/10 10:50
-	2659	((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)).CCLS.) and (lithography patterning)	USPAT; US-PGPUB	2003/06/10 10:50
-	559	(((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)).CCLS.) and (lithography patterning)) and (beam with radiation) (flood with electron with beam)	USPAT; US-PGPUB	2003/06/10 10:50
-	80	(((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and etching with polysilicon	USPAT; US-PGPUB	2003/06/10 10:51
-	26	(((430/328) or (438/671) or (438/723) or (430/313) or (430/296) or (438/371) or (438/719) or (438/720)).CCLS.) and (lithography patterning)) and (beam with radiation) (flood with electron with beam)) and (((lithography patterning) and (beam with radiation) (flood with electron with beam)) and (photoresist)) and etching with polysilicon)	USPAT; US-PGPUB	2003/06/10 10:51